

|    | L # | Hits  | Search Text  | DBs             |
|----|-----|-------|--|-----------------|
| 1  | L1  | 26084 | (inkjet or (ink or fluid or liquid) adj2 (jet\$4 or discharg\$4 or printhead or head)).ti,ab.  | US-PGPUB; USPAT |
| 2  | L2  | 56643 | ((substrate or base or support) with (remov\$4 or separat\$6)).ti,ab.  | US-PGPUB; USPAT |
| 3  | L3  | 428   | 1 and 2  | US-PGPUB; USPAT |
| 4  | L4  | 5646  | ((inkjet or ink or fluid or liquid) adj2 (printhead or head)).ti,ab.   | US-PGPUB; USPAT |
| 5  | L5  | 126   | 2 and 4  | US-PGPUB; USPAT |
| 6  | L6  | 948   | 430/320.ccls.  | US-PGPUB; USPAT |
| 7  | L7  | 9     | 3 and 6  | US-PGPUB; USPAT |
| 8  | L8  | 22505 | ((substrate or base or support) near3 (remov\$4 or separat\$6)).ti,ab.   | US-PGPUB; USPAT |
| 9  | L9  | 60    | 4 and 8  | US-PGPUB; USPAT |
| 10 | L10 | 1772  | 347/47,68,70.ccls.   | US-PGPUB; USPAT |
| 11 | L11 | 50    | 2 and 10   | US-PGPUB; USPAT |
| 12 | L12 | 32    | 11 not (7 or 9)  | US-PGPUB; USPAT |
| 13 | L13 | 13036 | (solubl\$6 or disolv\$6 or elut\$6) with (resin or polymer\$4 or photopolymer\$8 or sacrific\$8 or resist or photoresist or photosensitiv\$8 or path or channel or (photo or light or radiat\$4 or uv or ultraviolet) adj3 (sensitiv\$8 or polymeriz\$8 or polymeris\$8)).ti,ab. | US-PGPUB; USPAT |

|    | L # | Hits   | Search Text  | DBs                |
|----|-----|--------|--|--------------------|
| 14 | L14 | 289    | 1 and 13   | US-PGPUB;<br>USPAT |
| 15 | L15 | 2      | 6 and 14   | US-PGPUB;<br>USPAT |
| 16 | L16 | 3      | 10 and 13  | US-PGPUB;<br>USPAT |
| 17 | L17 | 15     | 4 and 13   | US-PGPUB;<br>USPAT |
| 18 | L18 | 293264 | (substrate or base or support) near3<br>(remov\$4 or separat\$6)   | US-PGPUB;<br>USPAT |
| 19 | L19 | 135603 | solubl\$6 or dissolv\$6 or elut\$6) with<br>(resin or polymer\$4 or photopolymer\$8<br>or sacrific\$8 or resist or photoresist or<br>photosensitiv\$8 or path or channel or<br>(photo or light or radiat\$4 or uv or<br>ultraviolet) adj3 (sensitiv\$8 or<br>polymeriz\$8 or polymeris\$8) | US-PGPUB;<br>USPAT |
| 20 | L20 | 1209   | 18 same 19   | US-PGPUB;<br>USPAT |
| 21 | L21 | 33     | 1 and 20   | US-PGPUB;<br>USPAT |
| 22 | L22 | 13     | takayama-hidehito.in.  | US-PGPUB;<br>USPAT |
| 23 | L23 | 52     | mouri-akihiro.in.  | US-PGPUB;<br>USPAT |
| 24 | L24 | 14     | yamaguchi-nobuhito.in.   | US-PGPUB;<br>USPAT |
| 25 | L25 | 3      | fukasaka-toshihiro.in.   | US-PGPUB;<br>USPAT |
| 26 | L26 | 20     | 1 and (25 or 22 or 23 or 24)   | US-PGPUB;<br>USPAT |

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|----|-----|--------|--|---|
| 27 | L27 | 29982  | (inkjet or ink or fluid or liquid) adj2<br>(printhead or head)   | EPO;<br>JPO;<br>DERWE<br>NT;<br>IBM_TDB |
| 28 | L28 | 100453 | piezoelectric  | EPO;<br>JPO;<br>DERWE<br>NT;<br>IBM_TDB |
| 29 | L29 | 3965   | 27 and 28  | EPO;<br>JPO;<br>DERWE<br>NT;<br>IBM_TDB |
| 30 | L30 | 99236  | solubl\$6 or dissolv\$6 or elut\$6) with<br>(resin or polymer\$4 or photopolymer\$8<br>or sacrific\$8 or resist or photoresist or<br>photosensitiv\$8 or path or channel or<br>(photo or light or radiat\$4 or uv or<br>ultraviolet) adj3 (sensitiv\$8 or<br>polymeriz\$8 or polymeris\$8) | EPO;<br>JPO;<br>DERWE<br>NT;<br>IBM_TDB |
| 31 | L31 | 9      | 29 and 30  | EPO;<br>JPO;<br>DERWE<br>NT;<br>IBM_TDB |
| 32 | L32 | 106740 | (substrate or base or support) near3<br>(remov\$4 or separat\$6)   | EPO;<br>JPO;<br>DERWE<br>NT;<br>IBM_TDB |
| 33 | L33 | 58     | 29 and 32  | EPO;<br>JPO;<br>DERWE<br>NT;<br>IBM_TDB |

|    | L # | Hits | Search Text | DBs                                     |
|----|-----|------|-------------|---|
| 34 | L34 | 55   | 33 not 31   | EPO;<br>JPO;<br>DERWE<br>NT;<br>IBM_TDB |